

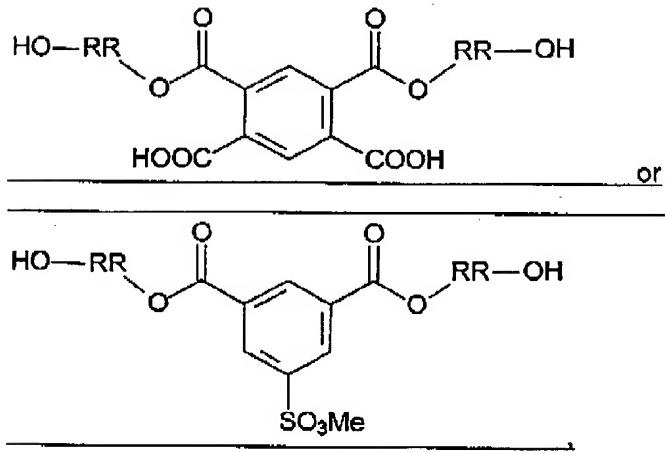
USS 10/017,157
Bei 756-KGB
Knuppel et al.

IN THE CLAIMS

Amend the claims as follows:

1. (Currently amended) A method Method-of protecting skin from exposure to light, said method comprising the topical administration of a cosmetic or dermatological O/W formulation comprising water-soluble or water-dispersible polyurethanes having improved water resistance and further comprising at least one UV filter substance, the method further comprising the steps of:

(a) topically applying to said skin a cosmetic or dermatological formulation comprising film-forming water dispersible polyurethane composition, wherein, the polyurethane composition comprises, at least one component formed by polyaddition of (i) at least one diisocyanate and (ii) at least one diol containing acid or salt groups having the structure



in which RR is in each case a C₂-C₁₈-alkylene group, and Me is Na or K.

USS 10/017,157
Bei 756-KGB
Knuppel et al.

,with (iii) a di-hydric or poly-hydric compound selected from the group consisting of diols, aminoalcohols, diamines, polyesterols, polyetherols; and

at least one UV filtering compound; and

(b) applying said composition to said skin to form a moisture resistant layer.

2. (Canceled).
3. (Original) The method as claimed in claim 2, wherein the O/W formulation is an emulsion.
4. (Original) The method as claimed in claim 2, wherein the O/W formulation is a microemulsion.
5. (Original) The method as claimed in claim 2, wherein the O/W formulation is a hydrodispersion.
6. (Previously amended) The method of claim 1, wherein the UV filter substance is water soluble.

USS 10/017,157

Bei 756-KGB

Knuppel et al.

7. (Original) The method as claimed in claim 1, wherein the cosmetic or dermatological preparations comprise, based on their total weight, from 0.1 to 10% by weight of polyurethanes.

8. (Previously amended) The method of claim 1, wherein the cosmetic or dermatological preparations comprise one or more water-soluble UV-A filter substances.

9. (Currently amended) The method as claimed in claim 1, further comprising least one broadband filter selected from the group consisting of one or more bis-resorcinyltriazines and derivatives thereof.

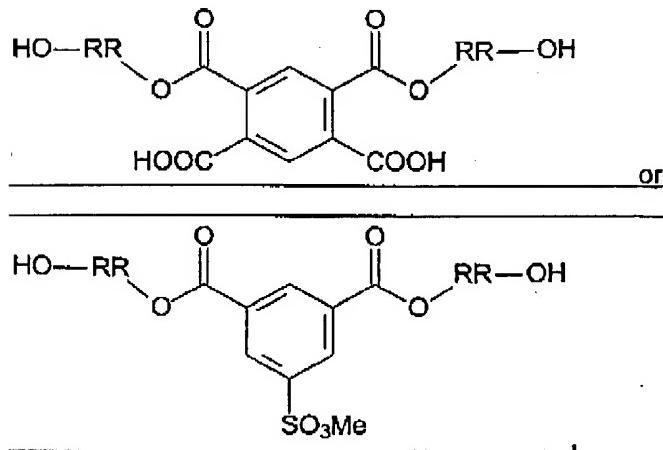
10. (Currently amended) The method of claim 1, further comprising at least one broadband UV filter, wherein said filter is a benzotriazole or derivative thereof.

11. (Currently amended) Method of protecting skin from exposure to light, said method comprising the topical administration of a cosmetic or dermatological O/W formulation comprising water-soluble or water-dispersible cationic polyurethanes having improved water resistance and further comprising at least one UV filter substance, the method further comprising the steps of:

(a) topically applying to said skin a cosmetic or dermatological formulation comprising a film-forming water dispersible polyurethane composition;

USS 10/017,157
Bei 756-KGB
Knuppel et al.

wherein, the polyurethane composition comprises at least one component formed by polyaddition of either,



in which RR is in each case a C₂-C₁₈-alkylene group, and Me is Na or K, with

~~at least one component formed by polyaddition of~~

(i) at least one diisocyanate that was optionally pre-reacted with one or more compounds that contain two or more active hydrogen atoms per molecule selected from the group consisting of, diols, aminoalcohols, diamines, polyesterols, polyetherols, and

(ii) at least one compound selected from the group consisting of, diols, aminoalcohols, primary or secondary diamines, or primary or secondary triamines having one or more tertiary, quarternary or protonated tertiary nitrogen atoms, and

at least one UV filtering compound; and

USS 10/017,157
Bei 756-KGB
Knuppel et al.

(b) applying said composition to said skin to form a moisture
resistant layer.

12. (Previously presented) The method of claim 8 wherein the one or more water-soluble UV-A filter substances is selected from the group consisting of phenylene-1,4-bis(2-benzimidazyl)-3,3'-5,5'-tetrasulfonic acid and/or 1,4-di(2-oxo-10-sulfo-3-bornylenemethyl)benzene and/or salts thereof.

13. (Previously presented) The method of claim 12, wherein the salts of the one or more UV-A substances are selected from the group consisting of the corresponding sodium, potassium, triethanolammonium salts and phenylene-1,4-bis(2-benzimidazyl)-3,3'-5,5'-tetrasulfonic acid bis-sodium salt.

14. (Previously presented) The method as claimed in claim 10, wherein at least one broadband filter is selected from the group consisting of 2,2'-methylenebis(6-(2H-benzotriazol-2-yl)-4-(1,1,3,3-tetramethylbutyl)phenol) and/or 2-(2H-benzotriazol-2-yl)-4-methyl-6-[2-methyl-3-[1,3,3,3-tetramethyl-1-[(trimethylsilyl)-oxy]disiloxanyl]propyl]phenol.

15. (Previously presented) The method as claimed in claim 9, wherein the broadband filter is 2,4-bis{[4-(2-ethylhexyloxy)-2-hydroxy]phenyl}-6-(4-methoxyphenyl)-1,3,5-triazine.